

Refine Search

Search Results -

Terms	Documents
L4 and (glass near5 transition)	22

Database:

US Pre-Grant Publication Full-Text Database
 US Patents Full-Text Database
 US OCR Full-Text Database
 EPO Abstracts Database
 JPO Abstracts Database
 Derwent World Patents Index
 IBM Technical Disclosure Bulletins

Search:

L5



Refine Search

Recall Text



Clear

Interrupt

Search History

DATE: Monday, September 19, 2005 [Printable Copy](#) [Create Case](#)

Set Name Query

side by side

Hit Count Set Name

result set

DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

<u>L5</u>	L4 and (glass near5 transition)	22	<u>L5</u>
<u>L4</u>	L3 and ((second or first) near5 (resist or photoresist))	196	<u>L4</u>
<u>L3</u>	L2 and ((pattern\$ or develop) same (resist or photoresist))	339	<u>L3</u>
<u>L2</u>	L1 and (anti reflect\$ or antireflect\$ or ARC)	921	<u>L2</u>
<u>L1</u>	((resist or photoresist) near3 flow\$) or RFP	11387	<u>L1</u>

END OF SEARCH HISTORY